

**Amendments to the Claims:**

This listing of the claims will replace all prior versions and listings of claims in the application:

**Listing of Claims:**

Claims 1-5 (Cancelled)

6 (Currently Amended): A method of manufacturing a metal product, comprising the steps of:

forming a resist pattern on a conductive substrate and exposing a portion of said conductive substrate;

immersing said conductive substrate having said resist pattern formed into ~~[[the]]~~ a molten salt bath for electroforming ~~according to claim 1~~, the molten salt bath for electroforming containing ~~chromium~~ or tungsten to be precipitated and/or a compound of ~~chromium~~ or tungsten to be precipitated; and

precipitating said ~~chromium~~, or tungsten at a portion where said conductive substrate is exposed, and

wherein said molten salt bath contains lithium bromide, cesium bromide, and a halide of an alkali metal and/or a halide of an alkaline-earth metal,

wherein a sum of a mole fraction of said lithium bromide and a mole fraction of said cesium bromide is set to be within a range from at least 0.5 to less than 0.95 with respect to entire said molten salt bath for electroforming, and a mole ratio of said lithium bromide to said cesium bromide (lithium bromide/cesium bromide) is set to be within a range from at least 1.8 to at most 2.5,

wherein said halide of the alkali metal is potassium bromide, and

wherein said metal product is composed of tungsten.

7 (Currently Amended): The method of manufacturing a metal product according to claim 6, wherein

a temperature of said molten salt bath for electroforming is set to at most 300°C in precipitating said ~~chromium~~ or tungsten.

8 (Cancelled)